



Optical Coatings for Laser Applications NTB Buchs, 9. Juni 2016

Prorektor, NTB, 9471 Buchs SG, Switzerland andreas.ettemeyer@ntb.ch | www.ntb.ch

Andreas Ettemeyer studied Mechanical Engineering in Munich and Aachen and graduated on holographic interferometry in Stuttgart. During nearly 20 years in industry, he concentrated on optical measuring techniques such as holography and speckle interferometry. In 1989 he founded and managed a company for production of laser measuring systems until he moved back to academia in 2005. Today he is professor for Technical Optics at NTB Interstate University of Applied Sciences in Buchs, Switzerland.

Prof. Dr. Andreas Ettemeyer

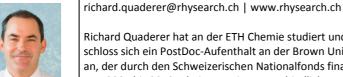


Dr. Richard Quaderer

Welcome note

Welcome note

CEO, Rhysearch, Buchs SG



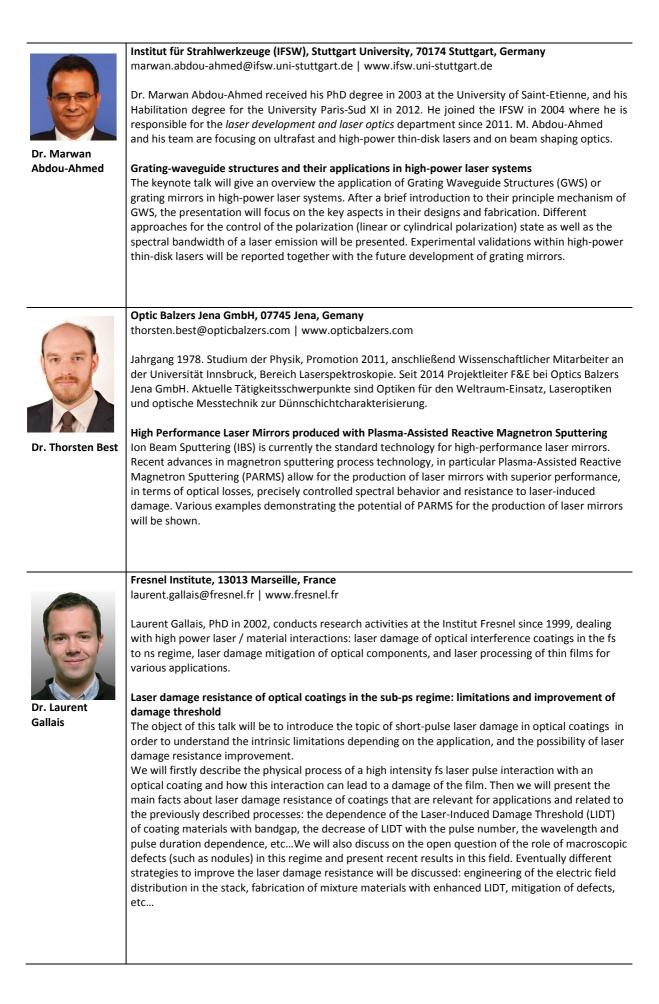
Richard Quaderer hat an der ETH Chemie studiert und hier auch seine Doktorarbeit verfasst. Daran schloss sich ein PostDoc-Aufenthalt an der Brown University in Providence, Rhode Island, in den USA an, der durch den Schweizerischen Nationalfonds finanziert wurde. Von 2007 bis 2013 arbeitete er in unterschiedlichen Positionen in der Biotechnologischen Forschung der Lonza AG in Visp VS. Berufsbegleitend absolvierte er an der EPFL und der Université de Lausanne einen Executive-MBA mit dem Schwerpunkt Technologiemanagement (MoT). Seit dem 1. Dezember 2013 ist Richard Quaderer Geschäftsführer von RhySearch.

Head Institute for Production Metrology, Materials and Optics (PWO), NTB, Buchs SG carsten.ziolek@ntb.ch | www.ntb.ch/pwo

Born 1972 in Gehrden, Germany. Studied Physics at the University of Hannover and received his doctorate degree on high-repetiton rate solid-state erbium lasers at the Laser Center Hannover. From 2001 to 2004 projekt leader at Trumpf Laser GmbH + Co. KG in Schramberg, Germany. Responsible for the development of the thin disk lasers HLD 251 & HLD 501 as well as fundamental aspects of the TruMicro Series 5000 und 7000 lasers.

Dr. rer. nat **Carsten Ziolek** From January 2004 till 2015 head of the Research & Development department of Trumpf Laser Marking Systems AG, Switzerland. Since 2015 Head PWO, NTB

Chairman am session + Conclusion



Prancel in 2008. Since November 2014 she is a senior research engineer at the PWO at NTB. 5 resolution of the LUDT measurement system and the build-up of the RhySearch centre for Opting the Costing. President Botha Posteroverview + LUDT testing at NTB As part of a KTL-Project, RhySearch and its partners form the photonics industry have joined for install a LUDT measurement facility at the NTB. The first results form the LUDT testbench are presented, together with the planned future developments for the RhySearch centre for Optic End Coatings. President Swissphotonics, 8832 Wollerau SZ, Switzerland harder@swissphotonics.net www.swissphotonics.net Dr. Christoph S. Harder received the ETH Diploma in 1979 and the Master and PhD in EE in 199 1903 from Caltech, Pasadena, USA. He is cofounder of the IBM Zurich Laser Diode Enterprise visor pioneered the first 9800 Fellow recognition. Christoph S. Harder received the ETH Diploma in 1979 and the Master and PhD in EE in 199 1903 from Caltech, Pasadena, USA. He is cofounder of the IBM Zurich Laser Diode Enterprise visor pioneered the first 9800 Fellow recognition. Christoph S. Harder received the TH Diploma in 1979 and the Master and PhD in EE in 199 1903 from Caltech, Pasadena, USA. He is cofounder of Swissphotonics and has bereide industrial and consumer applications with ultrahigh reliability. He is the recipient of a Fulbrigh scholariship and the OSA Fellow recognition. Christoph S. Harder Dr. Christoph S. Jublished more than 100 papers and 20 patents and has held a variety of staff and management positions at ETH, Caltech, IBM, Uniphase, JDS Uniphase, Nortel and Bookham an volunteered on society boards and committees. Chairman pm session F		
Pr. Christoph S. Harder@swissphotonics.net www.swissphotonics.net Dr. Christoph S. Harder received the ETH Diploma in 1979 and the Master and PhD in EE in 199 1983 from Caltech, Pasadena, USA. He is cofounder of the IBM Zurich Laser Diode Enterprise w pioneered the first 980nm high power pump laser for telecom optical amplifiers and laser diod industrial and consumer applications with ultrahigh reliability. He is the recipient of a Fulbrigh scholarship and the OSA Fellow recognition. Dr. Christoph S. Harder Harder Christoph S. Harder President for the last few years. He has published more than 100 papers and 20 patents and has held a variety of staff and management positions at ETH, Caltech, IBM, Uniphase, JDS Uniphase, Nortel and Bookham an volunteered on society boards and committees. Chairman pm session Friedrich Schiller University, Jena a.szeghalmi@uni-jena.de www.uni-jena.de Adriana Viorica Szeghalmi works interdisciplinary in the development of atomic layer depositif vorg. Germany. As a postochorchard file university of Manitoba in Canada, she conducted research field and got trained in Atomic Layer Deposition in Canada, she conducted research filed and got trained in Atomic Layer Deposition an Group at the Fraunhofer IOF. Her research focus at postochoral file university of Manitoba in Canada, she conducted research filed and got trained in Atomic Layer Deposition an Group at the Fraunhofer IOF. Her research focus is on the material development, refractive an diffractive optics by means of ALD. Overview of ALD Activities for Optical Applications ALD is a powerful coating technology for optical applications because		 roelene.botha@ntb.ch www.ntb.ch Roelene Botha received her PhD degree in Applied Physics at the Ecole Polytechnique, Palaiseau (France) in 2008. Since November 2014 she is a senior research engineer at the PWO at NTB. She is responsible for the LIDT measurement system and the build-up of the RhySearch centre for Optical High End Coatings. Posteroverview + LIDT Testing at NTB As part of a KTI-Project, RhySearch and its partners form the photonics industry have joined forces to install a LIDT measurement facility at the NTB. The first results form the LIDT testbench are presented, together with the planned future developments for the RhySearch centre for Optical High
 a.szeghalmi@uni-jena.de www.uni-jena.de Adriana Viorica Szeghalmi works interdisciplinary in the development of atomic layer depositic coatings for optical applications at the Friedrich Schiller University and Fraunhofer Institute of Applied Optics and Precision Engineering - IOF in Jena. She studied Chemistry and Physics in CI Napoca, Romania and did her PhD in Raman and surface enhanced Raman scattering spectros Würzburg, Germany. As a postdoctoral fellow at the University of Manitoba in Canada, she conducted research in the microspectroscopy of animal and plant tissues by means of infrared spectroscopy of animal and plant tissues by means of infrared work in a new research field and got trained in Atomic Layer Deposition (ALD) at the Max Plan Institute of Microstructure Physics in Halle (Saale, Germany). Since 2010, she has been leading Emmy Noether Research Group at the university and since 2015, she has been the head of an Group at the Fraunhofer IOF. Her research focus is on the material development, refractive and diffractive optics by means of ALD. Overview of ALD Activities for Optical Applications ALD is a powerful coating technology for optical applications because it allows uniform and co coatings on complexly shaped and nanostructured substrates. Besides, the composition and properties of ALD thin films are atomically tuned towards novel, multicomponent materials. H will present on the optical and mechanical properties and morphology of relevant oxides mad thermal and plasma enhanced ALD. Silica and nanoporous SiO₂, Al₂O₃, HfO₂, and TiO₂ have been developed as low and high refractive index materials. Interference multilayers such as antireficoatings, dichroic mirrors and various diffractive optics have been demonstrated. In particular 	-	harder@swissphotonics.net www.swissphotonics.net Dr. Christoph S. Harder received the ETH Diploma in 1979 and the Master and PhD in EE in 1980 and 1983 from Caltech, Pasadena, USA. He is cofounder of the IBM Zurich Laser Diode Enterprise which pioneered the first 980nm high power pump laser for telecom optical amplifiers and laser diodes for industrial and consumer applications with ultrahigh reliability. He is the recipient of a Fulbright scholarship and the OSA Fellow recognition. Christoph is now heading a consulting company and is cofounder of Swissphotonics and has been its president for the last few years. He has published more than 100 papers and 20 patents and has held a variety of staff and management positions at ETH, Caltech, IBM, Uniphase, JDS Uniphase, Nortel and Bookham and has volunteered on society boards and committees.
 a.szeghalmi@uni-jena.de www.uni-jena.de Adriana Viorica Szeghalmi works interdisciplinary in the development of atomic layer depositic coatings for optical applications at the Friedrich Schiller University and Fraunhofer Institute of Applied Optics and Precision Engineering - IOF in Jena. She studied Chemistry and Physics in CI Napoca, Romania and did her PhD in Raman and surface enhanced Raman scattering spectros Würzburg, Germany. As a postdoctoral fellow at the University of Manitoba in Canada, she conducted research in the microspectroscopy of animal and plant tissues by means of infrared spectroscopy and Surface-Enhanced Raman Spectroscopy (SERS). 2007, she returned to Germ. work in a new research field and got trained in Atomic Layer Deposition (ALD) at the Max Plan Institute of Microstructure Physics in Halle (Saale, Germany). Since 2010, she has been leading Emmy Noether Research Group at the university and since 2015, she has been the head of an Group at the Fraunhofer IOF. Her research focus is on the material development, refractive and diffractive optics by means of ALD. Overview of ALD Activities for Optical Applications ALD is a powerful coating technology for optical applications because it allows uniform and co coatings on complexly shaped and nanostructured substrates. Besides, the composition and properties of ALD thin films are atomically tuned towards novel, multicomponent materials. H will present on the optical and mechanical properties and morphology of relevant oxides mad thermal and plasma enhanced ALD. Silica and nanoporous SiO₂, Al₂O₃, HfO₂, and TiO₂ have been developed as low and high refractive index materials. Interference multilayers such as antireficoatings, dichroic mirrors and various diffractive optics have been demonstrated. In particular 		
ALD is a powerful coating technology for optical applications because it allows uniform and co coatings on complexly shaped and nanostructured substrates. Besides, the composition and properties of ALD thin films are atomically tuned towards novel, multicomponent materials. H will present on the optical and mechanical properties and morphology of relevant oxides mad thermal and plasma enhanced ALD. Silica and nanoporous SiO ₂ , Al ₂ O ₃ , HfO ₂ , and TiO ₂ have bee developed as low and high refractive index materials. Interference multilayers such as antirefl coatings, dichroic mirrors and various diffractive optics have been demonstrated. In particular	Dr. rer. nat. Adriana Viorica	 a.szeghalmi@uni-jena.de www.uni-jena.de Adriana Viorica Szeghalmi works interdisciplinary in the development of atomic layer deposition coatings for optical applications at the Friedrich Schiller University and Fraunhofer Institute of Applied Optics and Precision Engineering - IOF in Jena. She studied Chemistry and Physics in Cluj-Napoca, Romania and did her PhD in Raman and surface enhanced Raman scattering spectroscopy in Würzburg, Germany. As a postdoctoral fellow at the University of Manitoba in Canada, she conducted research in the microspectroscopy of animal and plant tissues by means of infrared spectroscopy and Surface-Enhanced Raman Spectroscopy (SERS). 2007, she returned to Germany to work in a new research field and got trained in Atomic Layer Deposition (ALD) at the Max Planck Institute of Microstructure Physics in Halle (Saale, Germany). Since 2010, she has been leading an Emmy Noether Research Group at the university and since 2015, she has been the head of an Attract Group at the Fraunhofer IOF. Her research focus is on the material development, refractive and
		ALD is a powerful coating technology for optical applications because it allows uniform and conformal coatings on complexly shaped and nanostructured substrates. Besides, the composition and properties of ALD thin films are atomically tuned towards novel, multicomponent materials. Here, we will present on the optical and mechanical properties and morphology of relevant oxides made by thermal and plasma enhanced ALD. Silica and nanoporous SiO ₂ , Al ₂ O ₃ , HfO ₂ , and TiO ₂ have been developed as low and high refractive index materials. Interference multilayers such as antireflection coatings, dichroic mirrors and various diffractive optics have been demonstrated. In particular current

	CEO, Cutting Edge Coatings Gmbh, 30419 Hannover, Germany starke@cutting-edge-coatings.com www.cutting-edge-coatings.com
(ANI Tomos	Born 1971 1992-1998 Physics Studies in Bielefeld and Hannover. 1998-2001 Scientific Co-worker of Laser Components Department (headed by Prof. Detlev Ristau) at
	Laser Zentrum Hannover e.V., (LZH)
	2001-2008 Group-Leader <i>Characterization</i> of Laser Components Department at LZH
Dr. Kai Starke	2004 PhD degree 2007 Foundation of Cutting Edge Coatings GmbH, CEO
	2013 Foundation of GIESS GmbH Gridded Ion Engines, Sources & Services, CEO
	Ion-Beam Sputtering in the Industrial Production
	Leading-edge applications in precision and laser optics demand functional surfaces with very low
	optical losses. Arising from innovative solutions for producing ring-laser gryo mirrors in the 1970s, IBS has conquered its central place in the family of industrial thin film deposition processes. In the presentation, general principles and current innovations and challenges are described.
	Group Leader, Ludwig-Maximilians-University, 80539 Munich, Germany vladimnir.pervak@physik.uni-muenchen.de www.uni-muenchen.de
(20)	
2	Vladimir Pervak received his MSc degree in Physics from the Kiev National Taras Schevchenko
	University, Ukraine, in 2004. In 2006, he received his PhD in Physics at the Max-Planck-Institute of Quantum Optics, Munich, and Kiev National Taras Schevchenko University. Currently, he is leading his
	team in the research group of Prof. Ferenc Krausz at the Max Planck Institute of Quantum Optics and
Du Madinain	Ludwig Maximilians University. He has more than 200 technical and scientific publications. His
Dr. Vladimir Pervak	research interests include interference coatings, ultrafast sources, and nonlinear optics.
	Dispersive optics: Limits and challenges
	Nowadays, dispersive mirrors are able to cover the wavelength range of 4.5 optical octaves and can be used from 220 nm up to 4500 nm. Various design approaches to dispersive mirrors in visible and near IR are briefly discussed. We consider in more detail two dispersive mirrors representing extreme cases. The first one is a mirror working in the range of 290–360 nm and providing group delay dispersion of -75 fs ² . The second one is a mirror working in the range of 1028-1032 nm and providing -10000 fs ² of group delay dispersion.
	Group leader, Vienna University, 1010 Vienna, Austria
	markus.aspelmeyer@univie.ac.at www.iqoqi.at
P	Markus Aspelmeyer is Professor of Physics at the University of Vienna, Austria. His research combines the development of new quantum technologies with fundamental quantum experiments. Aspelmeyer is a founding member and present Speaker of the Vienna Center for Quantum Science and Technology (VCQ). In 2012 he has co-founded the high-tech company <i>Crystalline Mirror</i> <i>Solutions</i> , which provides novel optics for laser precision measurements.
Prof. Dr. Markus	Crystalline Coatings - a new paradigm in optical coating technology
Aspelmeyer	Crystalline Coatings - a new paradigm in optical coating technology Substrate-transferred crystalline coatings allow to exploit the unique properties of single-crystal semiconductor coatings for high-end laser optics applications. In comparison with dielectric IBS coatings, crystalline coatings exhibit order of magnitude improvements in mechanical loss (i.e. thermal noise), thermal conductivity, and potentially in absorption losses in the mid-infrared spectral region. I will discuss the current status and provide several application examples including ultra- stable lasers, optical precision measurements, high-power SESAMs, and high-finesse MIR optical cavities in the fingerprint region for optical trace gas sensing.

	Head – Laboratory of Advanced Material Processing (LAMP), Epma, Materials Science and
	Technology, 3600 Thun, Switzerland
	patrik.hoffmann@empa.ch www.empa.ch
1sel	Adjunct Professor at The Laboratory for Photonic Materials and Characterization (LPMAT), Swiss
(and)	Federal Institute of Technology Lausanne, EPFL, Lausanne, Switzerland.
1 miles	Chemistry studies at University of Karlsruhe, PhD thesis at EPFL in 1992. Industrial experience at IBM
	San Jose (USA) and manager of dental section in company (Germany). Since 1997 research and
Prof. Dr. Patrik Hoffmann	teaching Laser Micro-Processing at EPFL. Since April 2009 heading LAMP at Empa, continuing
Horimann	teaching at EPFL. Author of 111 peer reviewed journal papers and inventor of 6 patents.
	Devastative contamination on DUV Laser mirrors and dreams for laser processing
	Excimer laser direct ablation is a unique method for large surface micropatterning of master polymer
	foils for large surface microstructuring. A volatile silicone oil, used as adhesion liquid for foil placing,
	turned out as devastative adsorbate destroying the DUV optics by deposition of a $SiO_2(C)$ layer. Digital micro-mirror devices as tools for direct pattern ablation remain a dream due to inflexibility of
	industry.
	VR RhySearch, Buchs SG
	hans.ebinger@rhysearch.com www.rhysearch.ch
	Upper Ebinger conducted recearch work in the field of surface science and holds a DhD in physics. Up
	Hans Ebinger conducted research work in the field of surface science and holds a PhD in physics. He started his professional career with the development of multilayer coaters for optical disc production.
	He moved from R&D to product management and finally general management of hightech
	companies. Hans Ebinger is a member of the RhySearch executive board and currently delegated to
Dr. Hans	set up a new research activity on precision manufacturing.
Ebinger	
	Workshop: Summary of presentations and discussion of current topics for development
	RhySearch is looking for future project ideas and seeks input from workshop participants. Every
	participant is kindly requested to write down one or two project ideas over the course of the day.
	These project ideas will be collected, screened and clustered for afternoon group discussion. The
	These project ideas will be collected, screened and clustered for afternoon group discussion. The resulting project proposals will be presented to the general audience at the end of the workshop.

SWISS*PHOTONICS

Managing director Dr. Christian Bosshard bosshard@swissphotonics.net +41 61 690 60 40 President Dr. Christoph Harder harder@swissphotonics.net +41 79 219 90 51

Internet www.swissphotonics.net

Dr. rer. nat Carsten Ziolek Coordinator SNOP (Swiss National Optics Platform) + 41 81 755 34 50 **Dr. Roelene Botha** Senior Research Engineer roelene.botha@ntb.ch +41 81 755 33 41 **Dr. Richard Quaderer** CEO RhySearch richhard. quaderer@rhysearch.ch +41 081 755 49 52